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Dielectric tensor of monoclinic Ga₂O₃ single crystals in the spectral range 0.5-8.5 eV

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The dielectric tensor of Ga_2O_3 in the monoclinic (β) phase was determined by generalized spectroscopic ellipsometry in a wide spectral range from 0.5 eV to 8.5 eV as well as by density functional theory calculations combined with many-body perturbation theory including quasiparticle and excitonic effects. The dielectric tensors obtained by both methods are in excellent agreement with each other and the observed transitions in the dielectric function are assigned to the corresponding valence bands. It is shown that the off-diagonal element of the dielectric tensor reaches values up to $|\varepsilon_{xz}| \approx 0.30$ and cannot be neglected. Even in the transparent spectral range where it is quite small ($|\varepsilon_{xz}| < 0.02$) it causes a rotation of the dielectric axes around the symmetry axis of up to 20°. © 2015 Author(s). All article content, except where otherwise noted, is licensed under a Creative Commons Attribution 3.0 Unported License. [http://dx.doi.org/10.1063/1.4934705]

Transparent conductive oxides (TCOs) are important materials for the realization of transparent electrodes,¹⁻³ e.g., for solar cells⁴ and transparent transistors.⁵ Up to now, indium tin oxide (ITO) is the material of choice in industrial applications. However, indium is quite expensive and therefore much effort is devoted to develop indium free TCO.² One promising material is Ga_2O_3 with a reported band gap energy of about 4.8 eV^{6,7} so that even in the presence of crystal imperfection high transmission in the visible and even in the UV-A/B spectral range can be obtained. Furthermore, the band gap energy is larger than the absorption edge of the atmosphere so that Ga_2O_3 is also a promising candidate for solar blind photodetectors.^{8,9}

The equilibrium crystal structure of Ga_2O_3 at ambient conditions is monoclinic, the so-called β -phase. The unit cell of this structure consists of eight Ga atoms which are surrounded by oxygen atoms where four Ga atoms exhibit an octahedral, the other four a tetrahedral coordination.¹⁰ The C_{2h} symmetry axis of this structure coincides with the crystallographic b-axis in real space and the lattice constants are about 1.22 nm, 0.30 nm, and 0.58 nm for the a, b, and c-axis, respectively. The angle γ between the a- and c-axis was determined to be 103.7° (Ref. 10). A schematic representation of the unit cell is shown in Fig. 1.

The band structure as well as the tensor of the dielectric function for β -Ga₂O₃ was calculated by several authors.¹¹⁻¹³ However, in these reports only the diagonal elements of the dielectric tensor were presented and the off-diagonal element was neither shown nor discussed. From the experimental point of view, there are optical characterizations of thin films by several groups.^{8,14–19} However, rotation domains present in the thin films and the inferior crystal structure compared to a single crystal prohibited the determination of the tensor components and only an effective dielectric function was measured. Experiments on single crystals are rare and mainly limited to transmission^{6,20} and absorp $tion^{6,7,21}$ measurements. From such data the entire dielectric tensor cannot be determined and only the absorption edges as well as the refractive index in the transparent spectral range were deduced. This strongly limits the comparison with theoretical calculations of the band structure.

Beside the crystal quality, there are also some experimental challenges. For the determination of the full tensor a series of polarization sensitive measurements at different crystal orientations are

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FIG. 1. Schematic representation of the unit cell of β -Ga₂O₃. The tetrahedrally coordinated Ga atoms are shown in blue whereas the octahedrally coordinated ones are shown in green. The oxygen atoms are marked in red. The (010) and the ($\overline{2}01$) planes are highlighted by the orange and red plane, respectively. (Image created by VESTA (Ref. 26).)

necessary and there are only a limited number of reports which deal with that problem, e.g., for α -PTCDA,^{22,23} pentacene,²⁴ and CdWO₄.²⁵

In this work, we present the full dielectric tensor of β -Ga₂O₃ within the spectral range 0.5–8.5 eV. We show that the off-diagonal element (ε_{xz}) has a significant impact on the orientation of the dielectric axes. This knowledge is important for polarization sensitive applications. The paper is organized as follows: first we describe the experimental setup, the investigated sample and present the theoretical framework which we used for the determination of the dielectric tensor. After that, the obtained dielectric tensor and the derived band structure are discussed.

For the investigations presented here, we have used two single side polished bulk single crystals (size of $10 \times 15 \times 0.65 \text{ mm}^3$) with different surface orientations, namely, ($\overline{2}01$) and (010). Both crystals were fabricated by the Tamura Corporation by means of floating zone technique and the surface planes of the two crystals are marked in Fig. 1. The crystalline quality of these crystals was investigated by X-ray diffraction measurements. For both samples, the out-of-plane rocking curve of the corresponding peak exhibits a full width at half-maximum of about 30–40 arc sec which indicates a highly ordered single crystalline sample with well aligned unit cells. Only the rocking curve of the skewed symmetric peak (200) or rather (111) exhibits three slightly twisted domains for both samples causing a small shoulder of the corresponding peak. Therefore, the FWHM of the mentioned peaks is 80 arc sec and 65 arc sec, respectively. Hints for the presence of twinning or in-plane domains were not observable. The as-received surface was investigated by atomic force microscopy (AFM) which revealed a smooth surface without atomic steps. The roughness was determined to be $R_s \approx 0.1 \text{ nm}$ (0.2 nm). This smooth surface and the absence of the atomic steps indicate an amorphous surface layer with possibly different optical properties than the bulk crystal.

The monoclinic structure causes an optically biaxial anisotropic behaviour with a refractive index and absorption edge depending on the polarization. In the case of β -Ga₂O₃ this dependence of the absorption edge on the polarization was explained by the symmetry of the valence bands and the conduction band by means of band structure calculation.^{11,13,27} The width of the valence bands was estimated to be about 7 eV. Surprisingly, it was found that the conduction band minimum is nearly isotropic.

The optical response of a material is described by its dielectric function (DF). For a monoclinic system this DF is a tensor given by²⁸

$$\varepsilon = \begin{pmatrix} \varepsilon_{\rm xx} & 0 & \varepsilon_{\rm xz} \\ 0 & \varepsilon_{\rm yy} & 0 \\ \varepsilon_{\rm xz} & 0 & \varepsilon_{\rm zz} \end{pmatrix}.$$
 (1)

The *y*-direction coincides with the symmetry axis. Since this is a symmetric tensor, it can be diagonalized for each photon energy separately. In the transparent spectral range, this diagonalization can be performed by a rotation of the framework and the corresponding diagonal elements are the semi-principal axes of the ellipsoid of wave normals.²⁸ These axes of the ellipsoid are also often called dielectric axes. The dispersion of each element of the dielectric tensor is in general independent from

the others so that the orientation of the dielectric axes with respect to the sample coordinate system depends on the photon energy.²⁹ This behaviour is called colour dispersion. For the tensor given by Eq. (1) one dielectric axis is fixed along the *y*-direction, whereas the other two rotate as a function of the photon energy in the *xz*-plane around the *y*-axis.

Spectroscopic ellipsometry was applied for the determination of the dielectric function of β -Ga₂O₃ in the spectral range of 0.5–8.5 eV. This method determines the change of the polarization state of incoming light after reflection on the sample surface^{30,31} which is usually expressed by the ratio of the complex reflection coefficients for light polarized perpendicular (s) and parallel (p) to the plane of incidence. However, in the case of an optically anisotropic material, conversion of s-into p-polarized lights takes place (and vice versa) and the change of the polarization state is then expressed by the 4 × 4 Mueller matrix *M* by $S_{ref} = MS_{in}$ with S_{in} (S_{ref}) being the Stokes vector of the incident (reflected) beam.³⁰ For the interpretation of the data, the Mueller matrix is often described as a matrix of four 2 × 2 block matrices. The diagonal block matrices are then mainly related to the different reflection coefficients for the p- and s-polarized light, whereas the off-diagonal block matrix describes the mentioned conversion of the polarization from s to p (and vice versa).

For the determination of the 4 independent complex quantities of the dielectric tensor (cf. Eq. (1)) the measurements have to be performed at different orientations of the dielectric axes with respect to the plane of incidence.²⁵ This was realized by using two bulk single crystals with the surface orientation mentioned above and by rotating each crystal around its surface normal by 0°, 45°, 90°, 105°, 180°, 225°, 270°, and 305° by using a motorized rotation stage in order to ensure a high sensitivity to each component of the dielectric tensor. The corresponding orientation of the sample system with respect to the laboratory system is then described by using the Euler angles (φ, ϑ, ψ) in the *yzx*-notation.³² For (φ, ϑ, ψ) = (0,0,0), the sample and the laboratory system coincide with each other. Since in Ga₂O₃ the angle between the crystallographic *a*- and *c*-axis is non-orthogonal, there is no direction which defines a Cartesian coordinate system in this plane. Therefore, we choose in the following the system defined by: $\hat{e}_x \parallel a$ -axis, $\hat{e}_y \parallel b$ -axis and $\hat{e}_z = \hat{e}_x \times \hat{e}_y$, \hat{e}_i being the unit vector in the *i* direction. As angles of incidence we have chosen 60° and 70°. For the measurements we used a commercial rotating analyzer type ellipsometer in PCSA³³ configuration. Thus, only the first three rows of *M* can be determined. The uncertainty of the measured block off-diagonal matrix elements is typically ±0.003.

For the determination of the dielectric function of Ga_2O_3 from the recorded spectra we used a layer stack model, consisting of the semi-infinite substrate, since reflections from the rough backside can be neglected, and a surface layer. Since both single crystals were fabricated by the same technique and produced by the same company, the dielectric function was assumed to be the same and analyzed simultaneously. The surface roughness of the samples was described by an effective medium approximation (EMA).³⁴ For both samples an effective thickness of about 2 nm was determined reflecting the smooth surface obtained by AFM. For the calculation of the DF of this layer, for simplicity only the diagonal elements of the dielectric tensor of Ga_2O_3 were considered and mixed with the DF of void with a fraction of 50%:50%.

By applying this layer model, the DF was obtained by using wavelength-by-wavelength analysis of the imaginary part ($\varepsilon_{2,ij}$) for each energy. The corresponding real part of the DF was then obtained by using Kramers-Kronig integration of the imaginary part using a commercial software.³⁵ For the contributions of the electronic transitions above the investigated spectral range, a pole function was considered. By doing so, the DF exhibits a non-vanishing imaginary part in the order of 10^{-3} in the visible spectral range. This causes a significant absorption in this spectral range which is physically wrong. This is probably caused by the unknown optical properties of the surface layer which can lead to such an effect, similar to an isotropic material where no surface layer is taken into account, and to the limitation of the used EMA model. However, due to the small thickness of this surface layer ($d_{\text{EMA}} \leq 2 \text{ nm}$) a determination of its DF, especially its anisotropic character, is quite challenging due to the low sensitivity to such a thin layer and the main results are unaffected by the choice of the surface layer. To overcome this problem, the experimental data were first analyzed in two different spectral ranges, namely a "transparent range" (0.5–4.0 eV) where the absorption is set to zero and the "absorption range" (3.0–8.5 eV) which includes the spectral range where absorption takes place.

In the "transparent range" (0.5–4.0 eV), the absorption was set to zero, i.e. $\varepsilon_{2,ij} = 0$, and the dielectric function can be fully described by its real part ($\varepsilon_{1,ij}$). For materials with an orthorhombic

TABLE I. Parameters of the tensor elements of the dielectric function of β -Ga₂O₃ in the transparent spectral range ($E \le 4$ eV).

	А	${ m B} (10^{-2}\mu{ m m}^2)$	$C (10^{-3} \mu m^4)$
ε_{xx}	3.479	4.727	1.753
ε_{yy}	3.626	4.739	1.242
ε_{zz}	3.574	4.882	2.129
ε_{xz}	0.016	-0.185	-0.146

(or higher) symmetry in this case the relation $n_i = \sqrt{\varepsilon_i}$ between the components of the refractive index (n_i) and the dielectric function holds where n_i can be described by a Cauchy approximation. In our case, due to the presence of the off-diagonal element this relationship is not valid anymore and we used

$$\varepsilon_{1,ij} = A_{ij} + \frac{B_{ij}}{\lambda^2} + \frac{C_{ij}}{\lambda^4} \,. \tag{2}$$

Note, by using this approximation a negative dispersion can be achieved as it can occur for the off-diagonal element of the dielectric tensor which is not possible by using a Cauchy approximation. The corresponding parameters are given in Table I.

The second range includes the "absorption range" (3.0–8.5 eV). Here, the DF was obtained by applying the wavelength-by-wavelength analysis as described above. In the spectral range where both parts overlap (3–4 eV) a good agreement between the DF deduced by the Cauchy approximation and the wavelength-by-wavelength fit was obtained. In order to obtain a single DF for the entire spectral range, the two parts of the DF were merged where a linear weighting function was applied in the overlap range. This weighting ensures a smooth onset of the imaginary part of the DF and was done in such a way that the transparent (absorption) spectral range contributes by 100% (0%) to the overall DF at an energy of E = 3 eV, whereas at E = 4 eV the contribution was set to 0% (100%). The overall dielectric function was than smoothed by using the Savitzky-Golay algorithm.³⁶

For the calculation of the band structure and the dielectric function, we determine in a first step the ground-state atomic structure by minimization of the energy with respect to all lattice parameters and ionic positions, employing density functional theory (DFT)³⁷ and the projector-augmented wave (PAW) method^{38,39} as implemented in the Vienna Ab-initio Simulation Package (VASP).^{40,41} In order to obtain structural data very close to experiment we used the AM05 gradient-corrected exchange-correlation (XC) functional.^{42,43} The shallow Ga 3*d* core states have been treated as valence. A plane-wave cutoff of 820 eV and a grid (Γ -centered) of 11 × 11 × 11 **k** points have been used for the structural optimization. The high plane-wave cutoff was necessary because we employ the calculated stress tensor for optimization of the lattice parameters and this stress tensor may suffer from spurious Pulay stresses due to the incompleteness of the basis set,⁴⁴ demanding for high plane-wave cutoffs.

The electronic excitations and optical spectra of β -Ga₂O₃ are calculated employing state-ofthe-art techniques based on many-body perturbation theory (MBPT).^{45,46} We use the GW scheme proposed by Hedin⁴⁷ for the XC self-energy, employing a HSE03⁴⁸ hybrid functional as starting point for the electronic quasi-particle band structure to calculate single particle excitation properties. The HSE03 starting point is chosen because the hybrid functional mimics already in a very crude manner parts of the quasi-particle effects. Hence, the GW corrections remain much smaller than for a DFT starting point justifying much better a single-shot G₀W₀ approach. For optical properties, the inclusion of excitonic effects, treated within the Bethe-Salpeter equation (BSE)^{45,46} framework, is crucial in order to allow a reasonable comparison with experimental spectra. We use the standard implementation of GW and BSE of VASP which employs the full frequency-dependent dielectric functions⁵⁰ for the calculation of the screened Coulomb interaction W and standard static screening in the BSE case.⁴⁵

For both, the GW and BSE calculations, we have to limit the **k**-point sampling to a grid of $8 \times 8 \times 8$ **k** points including the Brillouin zone center Γ point, due to the limitation of the computing capacity caused by the high number of unoccupied bands needed to achieve reasonable convergence

of the results. As a plane-wave cutoff we use a value of 410 eV. For the representation of the full microscopic inverse dielectric function entering the screened Coulomb interaction W in GW and BSE we can reduce the cutoff to 150 eV. All calculated optical spectra are smoothed with a broadening of 0.2 eV. Due to high computational demands we have to use a numerically very efficient time evolution scheme⁵⁰ to solve the Bethe-Salpeter equation where the calculation of the ω -dependent polarizability can be considered as an initial-value problem.⁵¹ This avoids the diagonalization of a giant pair Hamiltonian matrix with typical ranks of 300.000–400.000. However, one looses information about eigenvalues and eigenvectors of the BSE pair Hamiltonian matrix. Anyway, if bound exciton peaks can be observed below the fundamental gap energy one can at least estimate the bound exciton binding energies from the peak positions relative to the fundamental single-quasiparticle gap.

For selected crystal orientations with respect to the angle of incidence, the recorded and the calculated spectra of the Mueller matrix elements are shown in Fig. 2. A good agreement between the experimental and the calculated spectra can be recognized. The larger difference between the experimental and the calculated spectra for energies E > 7 eV compared to the entire spectral range



FIG. 2. Experimental (symbols) and model calculated (lines) spectra of the Mueller matrix elements for an angle of incidence of 70° for different orientations of the crystal. The definition of the Euler angles (φ, θ, ψ) on top of each column is the same as mentioned in the text.

This article is copyrighted as indicated in the article. Reuse of AIP content is subject to the terms at: http://aplmaterials.aip.org/about/rights_and_permissions Downloaded to IP: 139.18.24.114 On: Tue. 17 Nov 2015 08:15:59 can be attributed to the limitation of the approach used for the modeling of the surface layer as the reduced penetration depth in this highly absorbing spectral range enhances the contribution of the surface to the experimental data.

As can be seen, the off-diagonal elements of the Mueller matrix are strongly pronounced which reflects the anisotropic character of the sample and therewith mode conversion. This effect is especially pronounced in the absorption range. Generally, all of these off-diagonal elements differ from each other. However, for special crystallographic orientations some relationships can be found similar to the Jones matrix as reported in Ref. 25. A twofold rotation symmetry is observed in the case where the symmetry axis is perpendicular to the surface and the relationship $M_{13} = -M_{31}$ and $M_{23} = -M_{32}$ is obtained. If the symmetry axis is within the surface and parallel to the plane of incidence, then – changes to +. A vanishing of the off-diagonal elements can be observed if the symmetry axis lies in the surface plane and is perpendicular to the plane of incidence (Fig. 2(c)).

The DF derived from the best match between the experimental and calculated spectra is shown in Fig. 3(a). In the visible spectral range, the largest anisotropy is observed between the tensor elements for the x and y direction to be $\varepsilon_{yy} - \varepsilon_{xx} \approx 0.15$, whereas the difference between ε_{yy} and ε_{zz} is quite small (≈ 0.05). In the absorption range, the situation changes. In the diagonal elements, several peaks are observable caused by the transitions from valence bands into the conduction band. The first transitions occur for the dipole polarized perpendicular to the symmetry axis, namely, the z- and x-directions, at around $E \approx 4.8$ eV. The first one for a polarization along the y-direction is shifted around 500 meV to higher energies. This causes a more pronounced dispersion in the transparent spectral range for the ε_{xx} and ε_{zz} components as for the ε_{yy} . At two energies, namely, $E \approx 3.26$ eV and $E \approx 4.50$ eV, the dispersion of the elements ε_{zz} and ε_{xx} crosses with the one of ε_{yy} , respectively, causing two uniaxial points.

One important property, which is often neglected in the literature, is the monoclinic nature of β -Ga₂O₃, i.e., the presence of the off-diagonal tensor element of the DF. In the transparent spectral range (E < 4 eV), this element is small ($|\varepsilon_{1,xz}| < 0.02$) while in the absorption range several peaks are observable which reach values between -0.25 at $E \approx 4.8 \text{ eV}$ and $E \approx 6.9 \text{ eV}$ and 0.30 at $E \approx 5.1 \text{ eV}$. As already mentioned, the presence of the off-diagonal element causes rotation of the two dielectric axes in the *xz*-plane around the *y*-axis by an angle ϕ in dependence on the energy and the optical property given by

$$\tan 2\phi_i = \frac{2\varepsilon_{i,xz}}{\varepsilon_{i,xx} - \varepsilon_{i,zz}}.$$
(3)

Although the off-diagonal element in the transparent spectral range seems to be negligibly small, in conjunction with the dispersion of the diagonal elements, it causes a rotation by roughly 20° (inset Fig. 3(a)). In the absorbing spectral range, the magnitude of the tensor elements between the real part



FIG. 3. (a) Experimentally determined (left column) and theoretically derived (right column) tensor components of the dielectric function. Inset: Rotation angle of the dielectric axes around the *y*-axis for real (black) part and imaginary (red) part. (b) The calculated band structure of β -Ga₂O₃. The colour of the valence bands represents the polarization of the dipole-allowed transition into the lowest conduction band at the Γ -point (marked by arrows in (a)). The valence bands which have weakly dipole-allowed transitions are shown in light grey.

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and the imaginary part of the DF is different which leads to a different orientation of the corresponding ellipsoids. This is reflected by the different rotation angles $\phi_{1,2}$ of the corresponding dielectric axes around the *y*-axis. Therefore, the proposed model by Dressel *et al.*²⁴ for the description of the DF for a material with low symmetry (e.g., triclinic or monoclinic) cannot be applied in general since it assumes an accordance of the semi-major axis of the ellipsoids for the real part and imaginary part of the DF. This is in agreement with the results obtained on CdWO₄ by Jellison, Jr. *et al.*²⁵

The band structure calculated for low temperatures (T = 0 K) in the vicinity of the upper valence bands and the lowest conduction bands is shown in Fig. 3(b). By taking into account the symmetry of the bands and the corresponding transition matrix elements, the dielectric function is obtained and shown in Fig. 3(a), being in excellent agreement with the experimental one. The additional peaks in the theoretical derived DF compared to the experimentally determined can be attributed to artefacts due to the limited $8 \times 8 \times 8$ k-point sampling used for the calculation and the small broadening of the transitions considered in the calculations. For monoclinic crystals with 10 atoms in the unit cell a higher numerical precision is prohibited, especially because of the memory restriction mentioned above.

While the relative shifts of the spectra for the four tensor components in Fig. 3(a) agree between theory and experiment, the absolute positions of the edges in the imaginary parts show an energy shift of about 500 meV. Such a discrepancy has been also observed for other wide-band gap Ga compounds such as wurtzite-GaN, despite an almost equal description of the electronic quasiparticle gap and higher critical points by theory and experiment.⁵² Since the experimental observed transitions are blue shifted compared to the theoretical calculated, this shift can hardly be explained by the different temperature used for the calculation and in the experiment. A reason might be that electron-phonon interaction has to be taken into account in the calculations or maybe also additional screening effects due to free carriers, although a characterization of the sample indicates free-carrier concentrations below 10^{19} cm⁻³. Both might reduce the excitonic effects yielding a blue shift of the calculated spectra. However, the polaronic effects on the band structure shrinks the energy gap.⁵³ Also tensile strain in conjunction with a rather large deformation potential can be a potential reason. However, our calculated lattice parameters a = 1.229 nm, b = 0.305 nm, c = 0.581 nm, and $\beta = 103.77^{\circ}$ agree very well with the experimentally determined values and make this explanation rather unlikely. In order to get a deeper understanding of this energy shift, a precise description of the DF by means of model dielectric functions including an analysis in dependence on the temperature of the corresponding oscillators is necessary which is beyond the scope of this paper.

Despite this energy shift between the theoretical and experimental DF we can, however, note that otherwise the structure of the DF and, in particular, also the anisotropies are reproduced perfectly. We observe the same relative shifts and ordering of the peaks and onsets for different light polarisations in Fig. 3(a) and also the peak heights are reproduced correctly. This means essentially that the blue shift of the experimental spectra with respect to the theoretical ones is approximately a rigid shift.

From the calculated electronic structure and the symmetry of the bands the polarization and magnitude of the transition from the highest valence bands into the lowest conduction bands at the Γ -point are derived. The involved valence bands which contribute mainly to the DF and the polarization of the corresponding transitions are also indicated in Fig. 3(b). The energetic position of these transition in the experimentally derived DF are indicated by an arrow in Fig. 3. Except for the transitions from the first and second topmost valence bands into the conduction band which are dipole-allowed for a polarization mainly parallel to the *z*- and *x*-axes, respectively, the transitions are polarized either along the *y*-axis or within the *xz*-plane. This is in agreement with the DF determined by means of ellipsometry where the observed transitions above the absorption edge in the tensor elements ε_{xx} and ε_{zz} occur at the same energy and differ from those which appear in ε_{uy} .

To summarize, all tensor elements of the dielectric function of β -Ga₂O₃ were determined. This was done on the one hand experimentally by spectroscopic ellipsometry. On the other hand the DF was calculated by modern many-body theory including quasiparticle effects in the band structure calculations as well as excitonic and local-field effects in the calculation of the dielectric tensor. They have been shown to be in excellent agreement with each other. By means of band structure calculation, the observed transitions in the experimental dielectric function were assigned to the corresponding valence bands which explains the observed energy difference in the onset of the absorption for a dipole

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polarized along the symmetry axis and within the *xz*-plane of about 500 meV. Both, the experiment and the theoretical calculations, reveal a non-vanishing off-diagonal element which reaches values up to $|\varepsilon_{xz}| \approx 0.30$ in the absorption range. This element is responsible for the rotation of the dielectric axes and although it is quite small ($|\varepsilon_{xz}| < 0.02$), it causes a rotation of up to 20° in the transparent spectral range.

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